Silicon Metasurface Embedded Fabry-Pérot Cavity Enables High Quality Transmission Structural Color

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While nanoscale color generations have been studied for years, high performance transmission structural colors, simultaneously equipped with large gamut, high resolution, low loss and optical multiplexing abilities, still remain as a hanging issue. Here, beneficial from metasurfaces, we demonstrate a silicon metasurface embedded Fabry-Pérot cavity (meta-FP cavity), with polydimethylsiloxanes (PDMS) spacer and silver film mirrors. By changing the planar geometry of the embedded metasurface unit, the meta-FP cavity provides transmission colors with ultra large gamut of 194% sRGB and ultrahigh resolution of 141111 DPI, along with considerably average transmittance of 43% and more than 300% enhanced angular tolerance. Such high density allows two-dimensional color mixing at diffraction limit scale. The color gamut and the resolution can be flexibly tuned and improved by modifying the silver film thickness and the lattice period. The polarization manipulation ability of the metasurface also enables arbitrary color arrangements between cyan and red for two orthogonal linear polarization states, at deep subwavelength resolution. Our proposed
Cavities can be used in filters, printings, optical storages and many other applications in need of high quality and density colors.

1. Introduction

Advanced structural colors, supposed to combine pure colors with ultrahigh spatial resolution, optical multiplexing abilities and low loss, are essential for the development of various optical devices and applications such as displays, CMOS sensors, information storage and encryption. Recent years, because of the potential to satisfy these desires, artificial nanostructures for both reflective and transmissive colors have been widely studied. Such structural colors are always generated by various resonances supported in nanoscale resonators, including Mie resonances in dielectric scatters, surface plasmonic resonances excited in metallic structures, and Fabry-Pérot (FP) cavities. Although having been achieved for reflective colors recently, simultaneously realizing extremely wide color gamut and ultrahigh resolution is still challenging for transmissive colors.

Fabry-Pérot (FP) cavity is one of the most widely applied approaches to generate transmissive structural colors. Traditional FP cavities need to change the cavity lengths to adjust the colors, which require complicated nanofabrication processes for integration. Metasurfaces, composed of subwavelength unit arrays, have made planar FP cavities possible. The metasurface participated FP cavities are formed by embedding metallic or dielectric metasurfaces into the cavity
media, therefore the effective cavity lengths can be tuned with metasurface units. Previous works have explored their possibilities and developed related fabrication skills for both cavities with metallic mirrors and Bragg reflectors.

In this paper, we propose a silicon (Si) metasurface embedded FP cavity (meta-FP cavity) to generate transmissive structural colors with ultrawide color gamut, ultrahigh resolution and optical multiplexing abilities. Through simulation and optimization, a gamut coverage of 194% sRGB along with spatial resolution of 141111 DPI are achieved by our design. We carefully analysis the absorptive loss in the cavity and the color generation capacity at different spatial resolution. Taking advantage of such small units, we demonstrate high density color mixing and build printings with varying hue and saturation based on the mixing pixels. To overall estimate the performance, the influence of the silver (Ag) film thickness, the lattice period and the illumination angle are discussed. Finally, polarization multiplexed colorful display is also realized with embedded cross shaped nanopillars.

2. Results
2.1. Dielectric Metasurface Embedded Fabry-Pérot Cavity Design
The operation principle of the meta-FP cavity is illustrated in Figure 1a. The spatially variant phase responses of the dielectric metasurface introduce different effective cavity lengths along with varying transmission spectrums at each position. Si is selected to comprise the metasurface because of not only its high refractive index but also its high loss in short wavelengths. For reference, calculated absorbances in Si
films with different thicknesses are collected in Figure 1b. The absorption dramatically falls between the wavelengths of 380 nm and 500 nm, so the Si film can be regarded as a naturally high pass filter in the visible. Figure 1c depicts the metasurface unit composed of Si nano-cuboid with height $h_1$ and edge length $a$, centrally embedded in the UV PDMS$^{[41]}$ cuboid lattice with height $h_2$ and period $P$. The optical response is simulated and optimized by finite-difference time-domain (FDTD) approach through commercial software Lumerical FDTD Solutions (see Section S1, Supporting Information for simulation settings). For the unit with $h_1 = 50$ nm, $h_2 = 90$ nm and $P = 180$ nm, its phase and absorbance versus $a$ from 40 nm to 140 nm are simulated and shown in Figure 1d, under $x$ linear polarized normal incidence. With such units, short wavelength colors are mostly generated at small $a$ where transmittances are high, and partially absorbed at large $a$ to provide high purity long wavelength colors. The symmetric geometry of the metasurface unit also makes the color insensitive to polarization states.

As illustrated in Figure 1e, two Ag$^{[42]}$ films, with thickness $t = 35$ nm, are separately added to the bottom and the top of the metasurface unit, to constitute a meta-FP unit on a silica (SiO$_2^{[40]}$) basement. The small cavity length of 90 nm ensures only the first order FP mode is excited in the visible range. Meantime, the gap $g$ between the nano-cuboid and the Ag film reduces the plasmonic coupling, helping maintain the mode purity. Figure 1f shows the simulated relationship between the transmission spectrum and the edge length $a$, for $x$ linear polarized normal incidence. Since Ag films also
contribute to the phase accumulation, the FP peak deviates from the position where the phase of the metasurface unit is $\pi$ rad. Insert pictures in Figure 1f depict normalized electric field amplitude distributions in the $xz$ cross section plane, at the two markers respectively on plasmonic resonance and on FP resonance. The deep subwavelength period confines the plasmonic coupling peak to wavelengths around 400 nm therefore reduces its impact on color purity, while also centralizes all transmitting light to the zero-order diffraction to eliminate scattering. This fixed period also benefits printings with lattice matching between all units, leading to convenient and tight integration of colorful pixels. Although in use of the lossy Si, the maximal peak transmittance still reaches as high as 59% at the wavelength of 434 nm. The average peak transmittance is 43%, while the minimum of 39% arises at the wavelength of 570 nm. The full width of half maximum (FWHM) of the FP transmission peak, with an average value of 20.5 nm, appears to reach the maximum of 26.2 nm at the wavelength of 434 nm and gradually reduces to 18.5 nm as resonant wavelength increases.

The transmission spectrums are then translated into color coordinates using CIE 1931 chromaticity functions (see Section S2, Supporting Information) and plotted on CIE 1931 chromaticity diagram in Figure 1g. We calculate the maximum value, among the areas of all the closed curves linked between generated color coordinates, as the color gamut. Calculation shows the curve linking color coordinates of edge length $a$ from 40 nm to 137 nm covers the largest area, revealing an ultrahigh gamut coverage of
194% sRGB, 143% Adobe RGB, and even 102% Rec. 2020. As for the intersecting section with the standard color gamut, the coverage also reaches 100% of sRGB, 100% of Adobe RGB, and 91% of Rec. 2020. This means the generated colors are highly compatible with existing color systems.

**Figure 1.** Illustration of the Si meta-FP cavity and unit properties. a) Scheme of the meta-FP cavity. By tuning the 2D geometric cavity shapes of the embedded metasurface units, colors at different positions are widely adjusted. b) Calculated absorbances in Si films with different thicknesses. c) Scheme of an embedded metasurface unit, with fixed period $P = 180$ nm, Si nano-cuboid height $h_1 = 50$ nm, PDMS height $h_2 = 90$ nm. d) Simulated broadband phase and absorbance of the metasurface unit with varying edge length $a$, for $x$ polarized normal injection. e) Scheme of a meta-FP unit, made of the metasurface unit in (c), with two Ag films with thickness $t = 35$ nm and a SiO$_2$ basement. f) Simulated transmission spectrum of the meta-FP unit, under $x$ polarized
normal incidence imprinting from the bottom. Inserts show normalized electric field amplitude profiles in $xz$ plane cross sections, respectively at the pentagram marker on plasmonic resonance and at the hexagram marker on FP resonance. g) Corresponding color coordinates plotted with black points. The calculated color gamut is circled with the black line. White triangles from inside to outside respectively mark the gamut area of sRGB, Adobe RGB and Rec. 2020.

Besides the light field, we further analyze the optical loss in the meta-FP cavity. In the visible band, Si is always thought as a high lossy material because of its large real and imaginary part of the refractive index, therefore rarely used in transmissive devices. Here, as the thickness of the Si metasurface is only tens nanometers, its absorption is restricted to the similar level of the loss in Ag films. In Figure 2a-c, the absorption spectrums in two Ag films and Si, versus the edge length $a$, are respectively simulated and drawn. In short wavelengths, the Si metasurface strongly enhances the absorption, of the plasmonic induced transmissive modes and of the background light which is also absorbed by plasmonic resonances, which improves the purity of the color from chartreuse to red. To evaluate the loss contribution at the FP peak, the absorbance at peak wavelengths, respectively in Ag films and Si, versus the edge length $a$ are listed in Figure 2d. For small $a$, light trapped in Si nano-cuboid raises as $a$ enlarges, resulting in increased absorption. In contrast, when $a$ is large, due to the decreasing absorption of the Si in resonant long wavelengths, the absorbance drops. Though Si surely introduces more loss, its absorbance is well controlled for all meta-FP units, which is even below the loss in Ag films.
Figure 2. Absorption in the meta-FP cavity. a-c) Simulated broadband absorbance in (a) bottom Ag film, (b) top Ag film and (c) Si nano-cuboid. d) Absorbance in Si nano-cuboid and Ag films, at the FP transmission peak for each edge length $a$.

2.2. Ultrahigh Resolution

We first characterize the resolution with periodic red-green-blue-yellow (RGBY) filter arrays. Each color corresponds to $a = 140$ nm, 85 nm, 50 nm and 110 nm for the nano-cuboid. The size of the meta-FP unit array in every color pixel is set to 6×6, 4×4, 3×3, 2×2, 1×1, corresponding to spatial resolution of 23519 DPI, 35278 DPI, 47037 DPI, 70556 DPI, 141111 DPI. Each sample is illuminated by broadband normal incidence, successively under $x$ and $y$ linear polarizations. In the simulation, near field distributions of meta-FP cavity arrays are recorded in the SiO$_2$ basement, at the $xy$ plane 15 nm above the top Ag film. In this high refractive index environment, more details can be observed compared to free space. Next, at each wavelength, the transmission field is calculated by decomposing the recorded electric field into plane waves and then reconstructing with their transmission components through chirped $z$
transform, under a numerical aperture limitation of \( NA = \frac{n}{n_{SiO2}} \) (Section S3, Supporting Information). The wavelength related transmission intensities in every position are finally translated into color distributions one by one (raw CIE1931 XYZ data is dealt following Section S2, Supporting Information). As shown in Figure 3a, color filter arrays with pixels no smaller than 2×2 meta-FP units can generate highly pure and distinctive colors. To better compare the hue in variant conditions, brightness information in the dashed box is removed. Between pixels with different sizes and between different polarized illuminations, slight hue variations are observed, which mainly results from the weak coupling between adjacent meta-FP units. Such difference can be further compensated by integrally optimizing the sizes of the nano-cuboids. As for the color pixels with only 1×1 meta-FP unit, even when observed in SiO₂, their minute size of 180 nm falls below the resolution limit \( (0.61\lambda/n_{SiO2}) \) for wavelengths larger than 433 nm. Therefore, pixels providing long wavelength colors are nearly indistinguishable because of the observation resolution limit. In addition, colors from those indistinguishable pixels, especially the red and yellow pixels, overlap with surroundings and make the picture seeming orange. Also, the coupling and the excited extra resonances in such periodical subwavelength RGBY arrays disturb the color generation.

In order to demonstrate the color generation ability of a single meta-FP unit, we then test the light transmitting the FP cavity embedded only one isolate nano-cuboid. The single nano-cuboid is illuminated by a \( x \) polarized broadband Gaussian beam to
minimize the impact from surrounding transmissive light. Dashed box in Figure 3b shows the transmission color when without Ag films and the nano-cuboid. Color distributions of the same beam passing through the complete meta-FP cavities are also listed in Figure 3b, with the edge length $a$ varying from 40 nm to 180 nm. In each picture, the light traversing the PDMS FP cavity area forms the dark purple component, while some of it still mixes with the color generated by the meta-FP unit, causing the reduction of the color purity around the center. The transmission fields indicate that isolate meta-FP units can also generate high quality colors from purple to red, which verifies the ultrahigh resolution of 141111 DPI. A printing made of such extremely small pixels is further shown in the following Polarization Multiplexing part.

Figure 3. Spatial resolution test for the meta-FP cavity. a) Simulated periodic RGBY
filter arrays, with each color pixel containing 6×6, 4×4, 3×3, 2×2, 1×1 meta-FP units, corresponding to spatial resolution of 23519 DPI, 35278 DPI, 47037 DPI, 70556 DPI, 141111 DPI. The filter array is illuminated by normally impinging light, under \(x\) (upper) or \(y\) (lower) linear polarization states. b) Transmissive color profiles of the same Gaussian beam passing through different FP cavities embedded only one isolate nano-cuboid, with edge length \(a\) varying from 40 nm to 180 nm. Image in dashed box shows the color of the Gaussian beam going through the same space whereas without Ag films and nano-cuboid.

As a potential application of such deep subwavelength resolution, we realize highly dense color mixing. The mixing pixels, comprising 2×2 meta-FP units, are analyzed through two mixing types (Figure 4a) as an instance. By respectively varying the edge length \(a_1\) and \(a_2\) of two nano-cuboid groups marked with blue and red in a mixing pixel, the spectrum component is changed, which expands the color amount. We enlarge the size scope of \(a\) as 40 nm to 160 nm to cover more colors. In all simulations, the impinging light is set as normal injection with \(x\) linear polarization.

As depicted in Figure 4a, colors from only two mixing types cover many of the area within the 194% sRGB gamut. Figure 4b shows the transmission spectrums of four example mixing pixels, in which the lines are drawn in correspondingly generated colors and the inserts illustrate the pixel geometries. In the spectrum, long wavelength components possess larger transmittances than shorter wavelengths when the ratio of different meta-FP units is equal for Type 2. Some unexpected peaks are also generated. We attribute these to the coupling between meta-FP units and extra resonances excited by the periodical subwavelength mixing pixels.

We further print two colorful pictures, painted with varying hue and saturation, with 30×30 Type 1 mixing pixels, and check their color distributions through simulations.
As a reference, the relationship between mixing colors and edge length $a_1, a_2$ is given in Figure 4c. During the calculations of the observed images (Section S3, Supporting Information), the observation numerical aperture is reduced to NA = 1, corresponding to the resolution limit in free space. Figure 4d,e shows the edge length map and the simulated color distribution (without brightness information) of the first printing made of pixels marked in Figure 4c. The clear and colorful image proves that paintings and filters using the 2×2 mixing pixels are practical. Moreover, details of single meta-FP units are nearly invisible in free space, which reveals the excellent combination of the multiple color generation ability and the diffraction limit resolution. Around the edges of different color patterns, some extra colors are generated, because meta-FP units on both sides of the edge combine as new mixing pixels which provide different mixing colors. The color difference between the simulation and the design is attributed to the weak coupling, the extinction of nonlocal resonance in the aperiodic printing, and the reduction of the observation NA. In Figure 4f,g, we show the geometry and the simulated image (without brightness information) of the other printing which generates more colors but is with continuous structure variation. Since mixing pixels change smoothly in this printing, the display is cleaner and purer. Figure 4h depicts pictures of the mentioned two meta-FP printings, but shown with brightness information. Worth mentioning that the sizes of these two paintings, with spatially changing hue and saturation, are both only 10.8×10.8 μm², indicating our designed mixing pixels allow intensely colorful information encoding and storage. Meantime, with other mixing types added in, like simultaneously adjusting three or four meta-FP
units in the 2×2 pixel and enlarging the number of the units in one mixing pixel, the amount of color is expected to further grow.

Figure 4. Color mixing with 2×2 meta-FP units. a) Scheme of two types of mixing pixels and their simulated color coordinates, with edge length $a_1$ and $a_2$ varying from 40 nm to 160 nm. Blue and red squares represent two groups of units. Nano-cuboids in the two groups are with different edge lengths, of $a_1$ for blue and of $a_2$ for red. Gray line shows the 194% sRGB gamut of the meta-FP cavity. b) Normalized transmission spectrums of four selected mixing pixels, painted with corresponding mixing colors. Inserts depict mixing types and unit geometries. c) Relationship between mixing colors and edge length $a_1$, $a_2$, for Type 1 pixels. Circles mark all pixels chosen for the following printing. d) Map of edge length $a$, for a mixing printing made of 30×30 Type 1 mixing pixel array. All of the used pixels and desired display colors in this
printing are marked in (c). e) Corresponding simulated color profile, while brightness information is removed. f) Map of edge length $a$, for the other mixing printing made of 30×30 Type 1 mixing pixel array. Edge lengths vary smoothly in this printing. g) Corresponding simulated color profile, while brightness information is also removed. h) Colorful pictures recovered from the same spectrum data of (e) and (g), but with brightness information remained.

2.3. Flexible Cavity Properties

As different scenarios always require divers color properties, a structural color design would be wider applied if with easily regulable properties. In this part, the influence of the Ag film thickness $t$ and the lattice period $P$ are carefully studied, which shows high flexibility in color gamut and spatial resolution. Since the transmission spectrum is tightly connected with the mirror reflectance and transmittance for traditional FP cavities, such relationship is also satisfied in our meta-FP cavities. Quantitatively, we sweep the Ag thickness $t$ from 20 nm to 50 nm in step of 5 nm and collect the transmittance and color gamut in Figure 5a. Gamut curves of thickness $t = 20$ nm, 30 nm, 40 nm, 50 nm are shown in Figure 5b as instances. The average transmittance and the transmittance range are both computed only with the meta-FP units used to calculate the max color gamut. As $t$ increases from 20 nm to 50 nm, the color gamut gradually enlarges from 79% sRGB to as large as 232% sRGB, whereas the average transmittance also decreases from 71% to 11% because of the enhanced absorption in Si and Ag. When $t = 50$ nm, apart from the total coverage of 232% sRGB, the gamut also intersects with more than 97% of Rec. 2020, showing the suitability for extremely high-quality standard color generation. As for $t = 20$ nm, the high and homogeneous transmittance, with the maximum of 77% and the minimum of 71%, along with the substantial gamut of 79% sRGB, can benefit broad linewidth filters
with considerable efficiency.

Similarly, to illustrate the adjustable spatial resolution, the period $P$ is swept from 140 nm to 220 nm in step of 10 nm, while the edge length $a$ is limited between 40 nm and $P-40$ nm. As exhibited in Figure 5c, the gamut reaches the peak of 194% sRGB at $P = 190$ nm and drops either when $P$ increases or decreases, whereas the transmittance shows negative correlation to $P$. To illustrate the reasons of the gamut decline, the transmission spectrums of five selected meta-FP units respectively with $P = 140$ nm, 160 nm, 180 nm, 200 nm, 220 nm are listed in Figure 5d. While the FP peaks are all around the wavelength of 600 nm, the plasmonic induced resonances redshift when $P$ enlarges, which impact colors more significantly because of the larger tristimulus values in longer wavelengths. Meantime, as shown in the insert in Figure 5d, the increased background light, resulting from the weakened absorption in Si and Ag films, contributes to the dropped gamut at small $P$. However, for $P$ smaller than 180 nm, we attribute the rapid gamut drop mainly to the smaller peak wavelength tuning range which is collected in Figure 5c. This is because when $P$ falls, the maximum duty ratio of the Si nano-cuboid, appearing when $a = P-40$ nm, goes down, whereas the minimum duty ratio, showing at $a = 40$ nm, arises at the same time. As a solution, the range of the edge length $a$ is relaxed as 40 nm to $P-25$ nm, after which the color gamut is simulated and painted with dashed lines and hollow markers in Figure 5c. The obviously risen gamut reveals that with a cost of less than 15% sRGB coverage, extreme resolution of more than 180000 DPI is promising.
Figure 5. Influence of Ag thickness $t$ and meta-FP unit period $P$. a) Simulated color gamut and transmittance for Ag thickness $t$ from 20 nm to 50 nm. Pinky rectangles indicate transmittance varying ranges at each $t$. b) Gamut curves of $t = 20$ nm, 30, 40 nm, 50 nm. White triangles from inside to outside respectively mark the gamut area of sRGB, Adobe RGB and Rec. 2020. c) Color gamut and average transmittance for period $P$ from 140 nm to 220 nm. Lilac rectangles show FP peak varying ranges at each $P$. Purple solid lines and markers represent color gamut for $a$ varying from 40 nm to $P$-40 nm, while dashed lines and hollow markers are for $a$ from 40 nm to $P$-25 nm. d) Normalized transmission spectrums of selected meta-FP units at $P = 140$ nm, 160 nm, 180 nm, 200 nm, 220 nm, all with FP peaks around the wavelength of 600 nm. Insert zooms the transmittance curves between wavelengths of 400 nm and 550 nm.

2.4. Improved View Angles

For most applications of structural colors, light usually obliquely exposes onto the printed patterns, which requires the colors to stay unchanged under different incident angles. Fortunately, the high refractive index of Si also benefits the FP cavity with enhanced view angles.\cite{26, 43} To verify this, we set up a group of comparison between
Si meta-FP cavities and PDMS FP cavities, simulating their output spectrums under different incident angles widely ranging from 0° to 65°. In all simulations, the impinging light deflects in \( xz \) plane, successively with \( x \) and \( y \) linear polarization states. For meta-FP cavities, the edge lengths of the nano-cuboids are set to \( a = 50 \) nm, 85 nm, 100 nm, 110 nm, 140 nm, respectively with the FP peaks at the wavelengths of 449 nm, 519 nm, 555 nm, 578 nm, 654 nm. Figure 6a collects their normalized transmission spectrums under the oblique incidence. Overall, the mean relative deviation of the peak wavelength reaches around 1%, 2%, 3%, 4% when the incident angle enlarges to 23.6°, 35.4°, 44.4°, 55.9°, and maximal 4.5% at 65°. For comparison, we do the same simulations for five PDMS FP cavities with PDMS height \( h_2 = 122.5 \) nm, 150 nm, 162 nm, 172.5 nm, 200 nm, whose transmission spectrums are listed in Figure 6b. At the incident angle of 23.6°, 35.4°, 44.4°, 55.9°, 65°, the mean relative deviation of the peak wavelength in the PDMS FP cavity is as large as 2.8%, 5.9%, 8.7%, 12.4%, 15.1%, and respectively 280%, 316%, 290%, 310%, 335% greater than those of the meta-FP cavity. This indicates that the embedded high refractive index metasurface significantly improves the FP cavity’s performance through more than 300% compression of the angular induced transmission peak deviation. To directly reflect such improvement on the structural color, we calculate output colors from both meta-FP cavities and PDMS FP-cavities at different oblique angles. As drawn in Figure 6c, the obvious reduction of the chromatism in meta-FP cavities can be clearly found. By further diminishing the physical cavity length, the angular tolerance of the meta-FP cavity can be enhanced.
more.

Figure 6. Angular responses of meta-FP cavities and PDMS FP cavities. a) Simulated transmission spectrums of meta-FP cavities with selected edge length $a = 50$ nm, 85 nm, 100 nm, 110 nm, 140 nm, for $x$ (upper) and $y$ (lower) linear polarized light, and for oblique incidence from $0^\circ$ to $65^\circ$ in the $xz$ plane. b) Transmission spectrums of PDMS FP cavities with selected PDMS height $h_2 = 122.5$ nm, 150 nm, 162 nm, 172.5 nm, 200 nm, under the same illumination conditions. c) Calculated colors of above meta-FP cavities and PDMS FP cavities. Colors from meta-FP cavities show significantly reduced dependence on incident angles.

2.5. Polarization Multiplexing

High flexibility in manipulating polarization states is one of the best well-known
advantages of gradient metasurfaces. In this design, such advantage is well introduced to FP cavities and structural colors by the embedded metasurface. As shown in Figure 7a, instead of nano-cuboid, the cross shaped nanopillar, with arm length $w_1$, $w_2$ and fixed arm width $w_0 = 42$ nm, is embedded into the PDMS spacer to obtain the polarization-sensitive optical response. The nanopillar height $h_1$ and cavity length $h_2$ are adjusted to 70 nm and 100 nm to increase the color amount. Under $x$ linear polarized normal incidence, we sweep arm length $w_1$ and $w_2$ from 42 nm to 160 nm to get colors generated from the meta-FP units. For $y$ linear polarization, because of the geometrical symmetry, colors versus arm lengths are obtained by transposing results getting under $x$ polarized illumination. Figure 7b shows high purity transmission colors and their corresponding arm length $w_1$ and $w_2$, with which we can then arrange different colors for $x$ and $y$ linear polarizations and find proper meta-FP units to generate the desired patterns.

We first print a simple sample with 60×60 units, which separately displays “META” or “NANO” when illuminated by $x$ or $y$ polarized light. In each painting, colors of every letter and background are randomly picked from selected five colors, and circles in Figure 7b mark all the meta-FP units in need. The smallest pixel in the printing is set to 2×2 meta-FP units, corresponding to a pixel size of 360×360 nm$^2$ and spatial resolution of 70556 DPI. Figure 7c-e respectively depict the arm length maps, the generated pictures without and with brightness information. Since both pictures under two polarizations are clear and pure along with high saturation, our design
decouples the colors of two cross linear polarizations so permits flexibly multiplexed colorful coding. Next, two complex printings, displaying the pseudo color imaging of a ball and a cube, are separately encoded into \( x \) and \( y \) polarizations with 60×60 units. The geometries of nanopillars, shown in Figure 7f, are chosen following the color requirements in every position. The smallest pixel is set to 1×1 meta-FP unit to take use of the ultrahigh resolution of 141111 DPI. As shown in Figure 7g,h corresponding to images without and with brightness information, two paintings are both well generated without any overlap or interference between each other. This indicates that the designed meta-FP cavity enables arbitrary pure color arrangements between cyan and red for orthogonal linear polarization states, under sub diffraction limit resolution. By unlocking more adjustable geometrical parameters like two arm widths, the wider and more complicated color switching is promising. Moreover, such design is also compatible with the color mixing pixels discussed above, which brings extreme density and flexibility to colorful multiplexed optical storage and encryption.
Figure 7. Polarization multiplexed display with meta-FP cavity. a) Scheme of a metasurface unit with an embedded cross shaped nanopillar, and a meta-FP unit made of it. Geometry parameters, $P$, $w_0$, $h_1$, $h_2$, $t$, are fixed to 180 nm, 42 nm, 70 nm, 100 nm, 35 nm. b) Colors from meta-FP cavities for $w_1$ and $w_2$ varying from 42 nm to 160 nm, and for $x$ (left) and $y$ (right) linear polarized normal incidence. Circles indicate all unit geometries required for the following printing. c) Maps of arm length $w_1$ (upper) and $w_2$ (lower), for a multiplexed printing made of 60×60 meta-FP units. The printing is designed to display “META” under $x$ linear polarization and “NANO” under $y$ linear polarization. All of the used units are marked in (b). d) Corresponding simulated color distributions under $x$ (left) and $y$ (right) linear polarized normal illuminations. Brightness information is removed to clearly show the hue. e) Pictures recovered from the same spectrum data of (d), whereas remaining brightness information. f) Maps of arm length $w_1$ (upper) and $w_2$ (lower), for the other multiplexed printing made of 60×60 meta-FP units. The printing is designed to display the pseudo color imaging, of a ball under $x$ linear polarization and of a cube under $y$ linear polarization. g,h) Corresponding simulated color distributions, (g) without and (h) with brightness information.
3. Conclusion

In summary, we have proposed and simulated a Si metasurface embedded Fabry-Pérot cavity to generate high quality transmission structural colors. The designed meta-FP cavity provides colors with ultrawide gamut of 194% sRGB and ultrahigh resolution of 141111 DPI, along with an average transmittance of 43%. Its deep subwavelength scale enables two-dimensional color mixing under diffraction limit resolution. By adjusting the Ag mirror thickness and the unit period, the color gamut and resolution can be flexibly regulated and improved respectively up to more than 232% sRGB and 180000 DPI. Compared with regular PDMS FP cavity, the embedded Si metasurface enhances the angular tolerance by more than 300%. As for polarization multiplexing, the meta-FP cavity decouples the colors of orthogonal linear polarization states and enables totally different printing encoding. Our meta-FP cavity can be applied in most occasions in need of transmission structural colors, like CMOS and display filters, optical encryption and information storage. As a connection between metasurfaces and colors, further studies might be able to introduce more advantages of gradient metasurfaces into cavities and structural colors.

Supporting Information
Supporting Information is available from the Wiley Online Library or from the author.

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A silicon metasurface embedded planar Fabry-Pérot cavity is proposed to generate high quality transmission structural colors with ultrawide gamut of 194% sRGB, ultrahigh resolution of 141111 DPI, average transmittance of 43% and more than 300% enhanced angle tolerance. Diffraction limit color mixing and subwavelength polarization multiplexing are also achieved with our design.

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Silicon Metasurface Embedded Fabry-Pérot Cavity Enables High Quality Transmission Structural Color
Supporting Information

Silicon Metasurface Embedded Fabry-Perot Cavity Enables High Quality Transmission Structural Color

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Section S1. Simulation Settings

Figure S1 shows the simulation environment of the meta-FP cavity unit as an example. In most simulations, the mesh setting is default accuracy level 3, and an extra mesh area, with grid step of \( d_x = d_y = 5 \) nm and \( d_z = 3 \) nm, is added around the meta-FP cavity to fix the grid and increase the simulation accuracy. As for the boundary conditions in \( x \) and \( y \) direction, Symmetrical/Asymmetrical boundary is used for the simulations of metasurface units and meta-FP units when under normal incidence. Periodic boundary is used for the simulation of RGBY filter arrays and mixing pixels. PML boundary is used for the isolate meta-FP cavity units with Gaussian beam injections, and printing patterns. Boundaries in \( z \) direction are set to PML for all simulations. Light injects normally from the bottom with broadband pulse ranging from 380 nm to 780 nm, for all simulations except those about angle responses. The auto shut off value is fixed to 1e-5.

When simulating the optical response under oblique incidence, boundaries in \( x \) direction are set as Bloch, while boundaries in \( y \) direction are set to Symmetric or Asymmetric for \( x \) or \( y \) polarized injections. We sweep the wavelength from 380 nm to
780 nm to get broadband transmittance.

In the simulation of PDMS FP cavity, \(dz\) in the extra mesh area is reduced to 0.5 nm to obtain the relationship between the output spectrum and the cavity length in step of 0.5 nm.

Figure S1. The simulation environment for the meta-FP unit shown in Figure 1, observed along a) z direction and b) y direction.

**Section S2. Calculation of Color Coordinates**

The used normalized CIE 1931 color stimulus function \(CIEX_0, CIEY_0, CIEZ_0\) is depicted in Figure S2. For the simulation of single meta-FP units and color mixing pixels, the CIE XYZ values are calculated with simulated transmittance through following equations

\[
\begin{align*}
X_0 &= \int_{380}^{780} CIEX_0 \times T(\lambda) d\lambda \\
Y_0 &= \int_{380}^{780} CIEY_0 \times T(\lambda) d\lambda \\
Z_0 &= \int_{380}^{780} CIEZ_0 \times T(\lambda) d\lambda
\end{align*}
\] (S1)
Where \( T(\lambda) \) is the transmission spectrum. Then \((X_0, Y_0, Z_0)\) is transformed into CIE xy coordinates by

\[
\begin{align*}
x_{\text{CIE}} &= \frac{X_0}{X_0 + Y_0 + Z_0} \\
y_{\text{CIE}} &= \frac{X_0}{X_0 + Y_0 + Z_0} \\
z_{\text{CIE}} &= 1 - x_{\text{CIE}} - y_{\text{CIE}}
\end{align*}
\] (S2)

For the simulation of spatial varying pictures, the CIE XYZ values are calculated with transmission power in each position

\[
\begin{align*}
X_0(x, y) &= \int_{380}^{780} \text{CIE}X_0 \times I_T(\lambda, x, y) d\lambda \\
Y_0(x, y) &= \int_{380}^{780} \text{CIE}Y_0 \times I_T(\lambda, x, y) d\lambda \\
Z_0(x, y) &= \int_{380}^{780} \text{CIE}Z_0 \times I_T(\lambda, x, y) d\lambda
\end{align*}
\] (S3)

Where \( I_T(\lambda, x, y) \) is the transmission electric field intensity at position \((x, y)\). Then \((X_0, Y_0, Z_0)\) is transformed into CIE xy coordinates by

\[
\begin{align*}
x_{\text{CIE}}(x, y) &= \frac{X_0(x, y)}{X_0(x, y) + Y_0(x, y) + Z_0(x, y)} \\
y_{\text{CIE}}(x, y) &= \frac{X_0(x, y)}{X_0(x, y) + Y_0(x, y) + Z_0(x, y)} \\
z_{\text{CIE}}(x, y) &= 1 - x_{\text{CIE}}(x, y) - y_{\text{CIE}}(x, y)
\end{align*}
\] (S4)

For displays without brightness information, \((x_{\text{CIE}}, y_{\text{CIE}}, z_{\text{CIE}})\) is translated into RGB value using the function “xyz2rgb” in MATLAB, with the gamut sRGB and the white point d65. For displays with brightness information, we integrally change the spectrum intensities with coefficient \( k \) to adjust the brightness for a better display, corresponding to observing under proper illumination power. The adjusted CIE XYZ
value is

\[ \begin{align*}
X(x, y) &= kX_0(x, y), \\
Y(x, y) &= kY_0(x, y), \\
Z(x, y) &= kZ_0(x, y)
\end{align*} \]  \hspace{1cm} (S5)

Then \((X, Y, Z)\) is translated into RGB value using the function “xyz2rgb” in MATLAB, with the gamut sRGB and the white point d65.

Since the gamut coverage in our paintings is larger than sRGB, the calculated RGB values exist some smaller than 0 or larger than 1. Those values smaller than 0 are all replaced by 0, and those larger than 1 are all replaced by 1.

Figure S2. Normalized CIE 1931 color stimulus function.

Section S3. Calculation of the Observation Image

The calculation, based on the vector angular spectrum method, follows two steps.

First, the simulated electrical field is decomposed into plane waves with the build-in function “farfieldvector3D” for aperiodic structures (printings in 2.2, 2.5 and Gaussian beams in 2.2) and “gratingvector” for periodic structures (RGBY arrays in 2.2) in FDTD Solutions. The numerical aperture limitation is added as a filter on the angular spectrum. Second, the angular spectrum back propagates to the observation plane, which is calculated by chirped z transform through build-in function “czt”.